

Shanghai Deep UV-FEL Control System

Control Group

Ding Jianguo 2009/2/13

SDUV-FEL Control System

- Introduction
- System Design
- Device control
 - Power supply control
 - Vacuum control
 - Microwave control (Phase shifter, modulator...)
- Timing and Interlock
- Others

Introduction

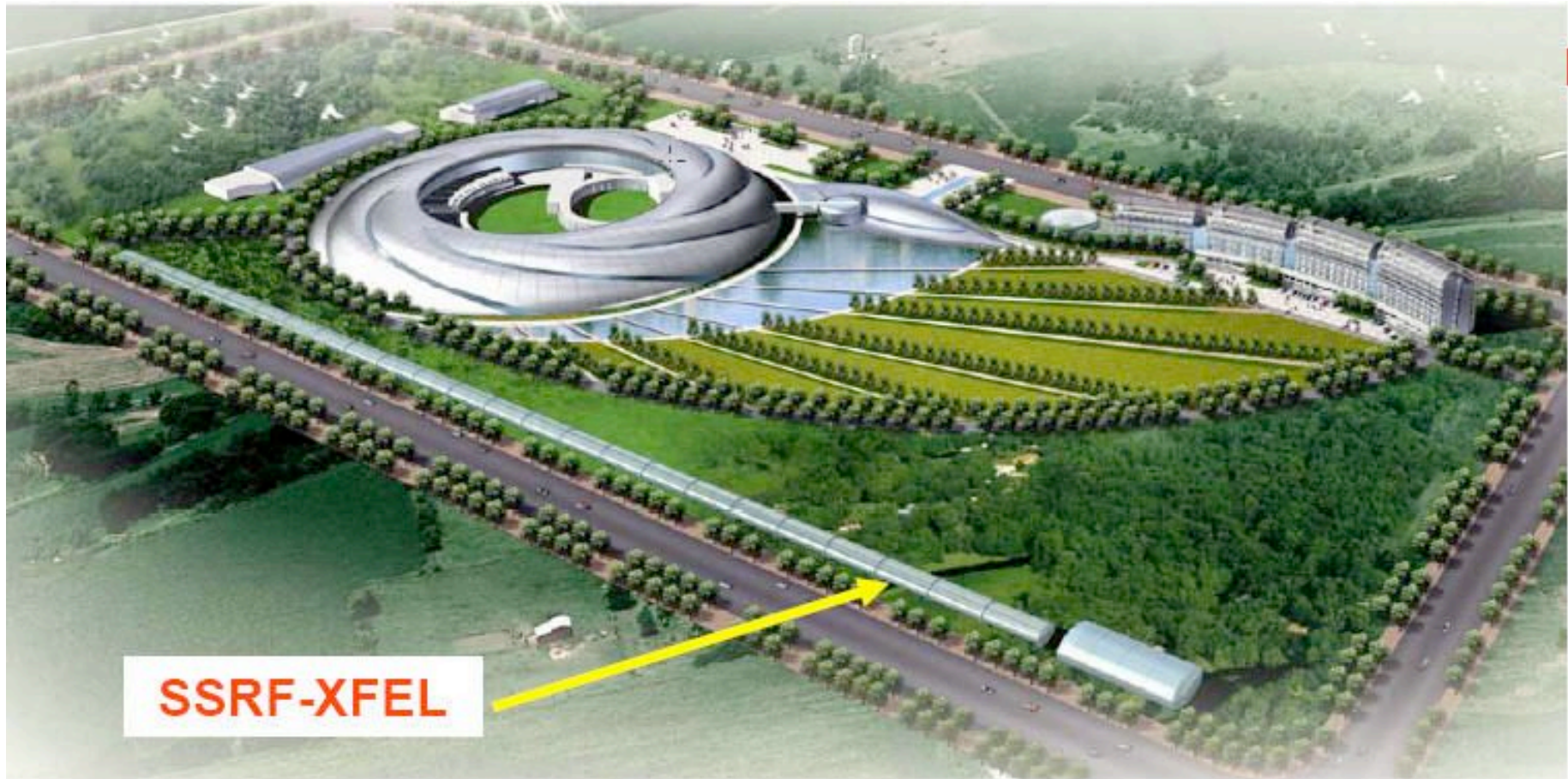
- SDUV-FEL is pre-search of chinese hard X-ray FEL
- There are several FEL facilities is under construction
 - LCLS (Linac Coherent Light Source)
 - EURO-XFEL
 - SCSS(SPring-8 Compact SASE Source)
- SDUV-FEL control system is an extended system based on 100Mev linac control system
 - Keep no change to those old devices which existed in 100Mev
 - New devices will be added in through extended cards/buses
 - Almost all of new devices can use the control method in SSRF
- Total system can be separated to following sub systems
 - Injector sub-system
 - Linac sub-system
 - Undulator sub-system
 - Timing and interlock sub-system

Normal Operation of SDUV FEL



Parameters	Value
Seed laser wavelength	1048 nm
Seed laser duration	10 ps
Electron beam duration	2 ps
Electron beam energy	160 MeV
Peak current	300 A
Normalized emittance	6 mm-mrad
Local energy spread	5×10^{-5}
Modulator period length	50 mm
Modulator length	0.80 m
Modulator gap	Alterable
Radiator period length	25 mm
Radiator length	9.00 m
Radiator gap	10 mm
Radiator resonant wavelength	262 nm

Future Plan

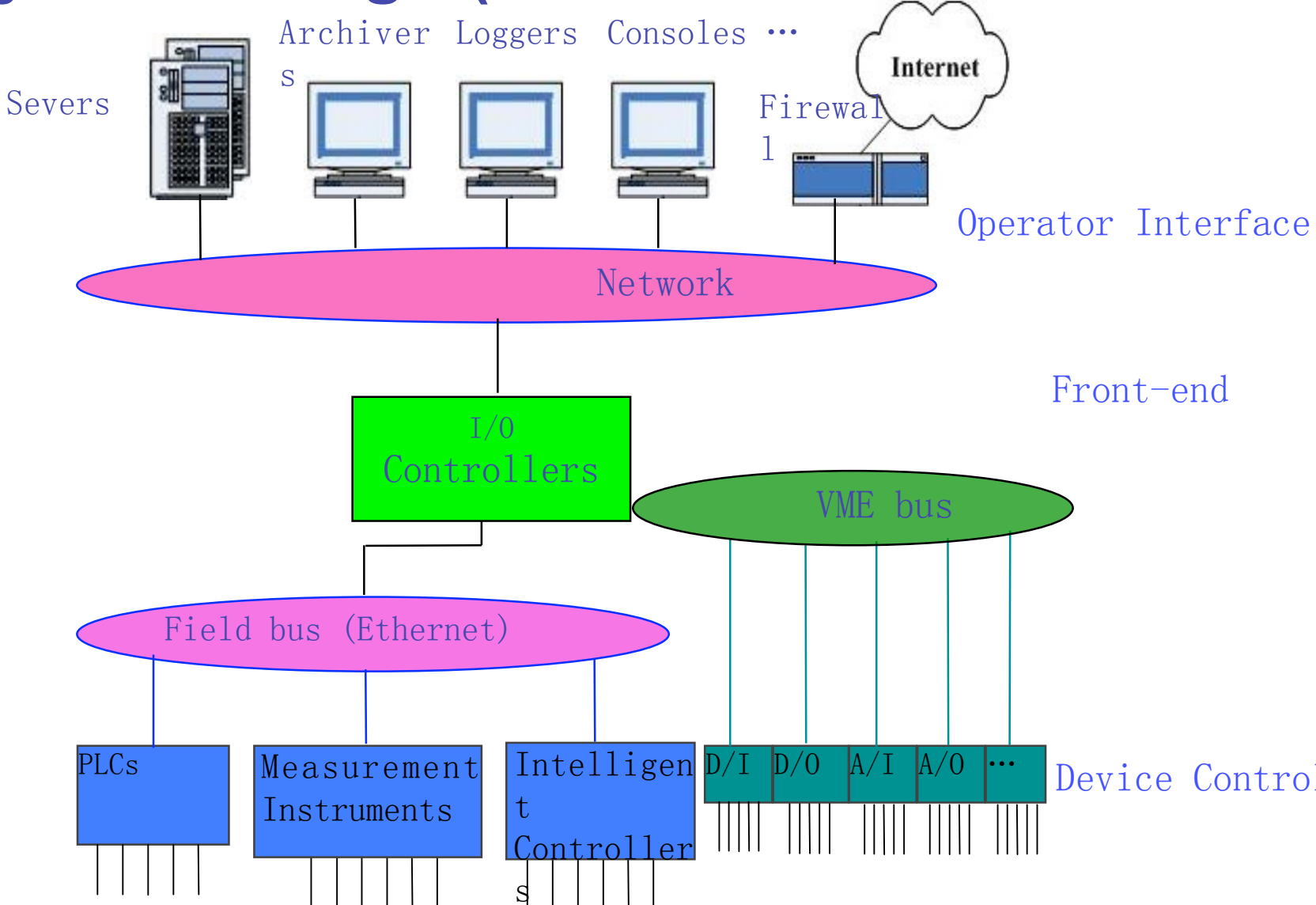


SSRF-XFEL

System Design

- SDUV-FEL control system is a distributed system based on “Standard Model”
- OPI Layer
- Front-end Layer
- Device control Layer
 - Ps controller
 - Vacuum controller
 - Pump ps controller
 - PLC, etc.
- Network/filedbuses
 - LAN, DeviceNet, serial, etc.
- As we upgrade from the old control system, we obey the rules “use old devices as much as possible”

System Design (Architecture)



System Design (Hardware)

■ 1 EPICS file/data server

- FTP Server
- NTP Server
- NFS Server
- Data Archiver
- Running soft IOCs

■ 4 OPI computers

- Including original 2 Desktops

■ 7 IOCs

- Including original 3 servers, add 4 new VME7050

■ Device controller

- Already 1 PLC (For vacuum interlock)
- Add 2 new I/O modules
- Other device controllers are maintained by other groups

System Design (Software)

■ OS

- OPI: Scientific linux
- IOC: vxWorks 5.5.1
- EPICS Server: Scientific linux

■ EPICS base

- base 3.14.8.2 / 3.14.9

■ OPI Interface

- edm

■ Other tools

- StripTool, AlarmHandler, Channel Archiver, etc.

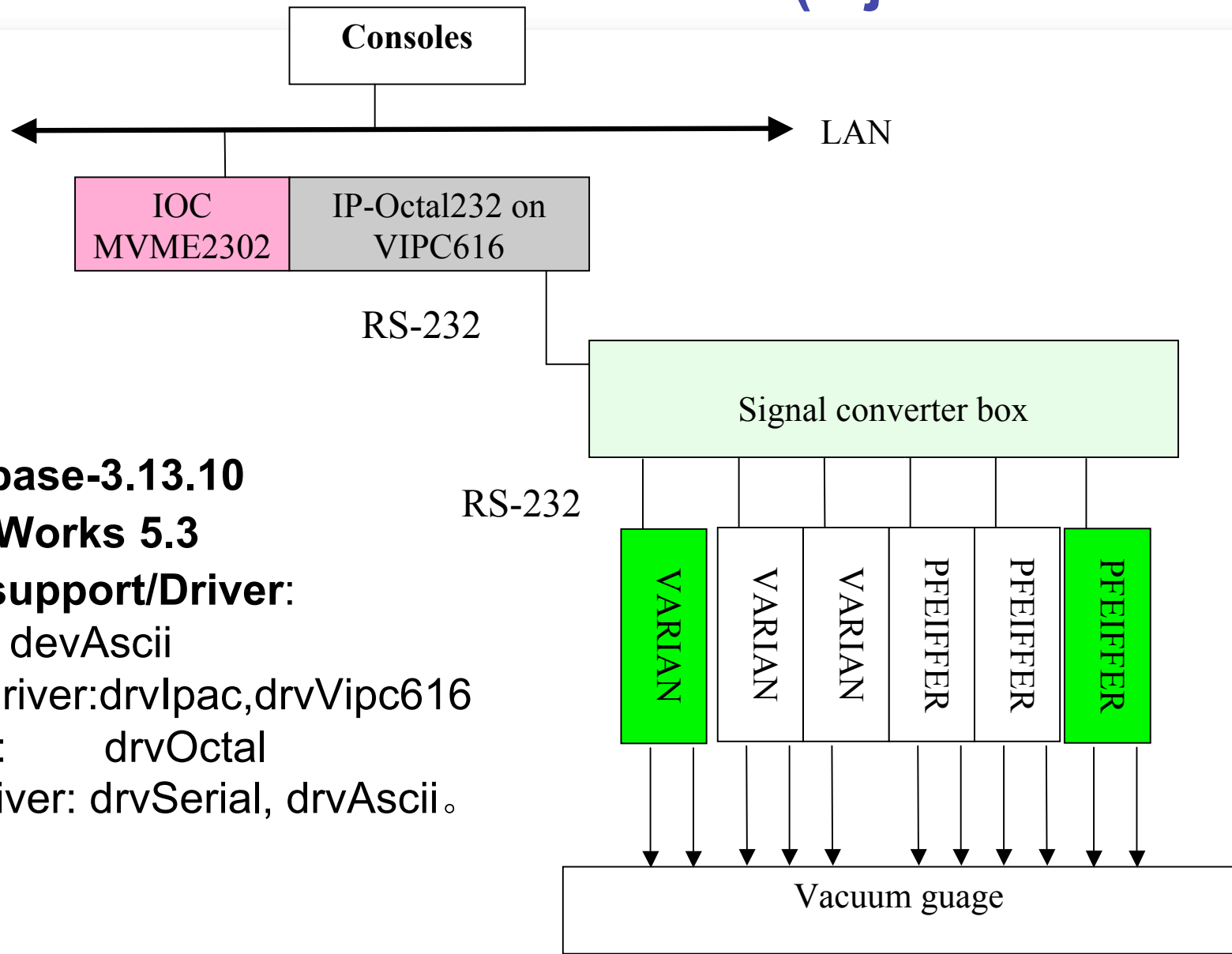
Device Control (Magnets Power Supply)

- Power supply of Injector and linac
 - Old power supplies are kept to be used
 - Some new homemade digital power supplies are added
- Magnet's power supply in undulator
 - Takes new homemade digital power supplies
- Two types of PS, two types of interfaces in our system
 - DeviceNet
 - Ethernet

Device Control - Vacuum Monitor

- Main part of injector and linac
 - Keep the same control method of 100Mev in injector and Linac
 - Add two vacuum gauges (1 Varian, 1 Pfeiffer), control in the same way as above
- Undulator
 - 6 vacuum gauges (one leybold, others undefined)
 - Controlled through Ethernet

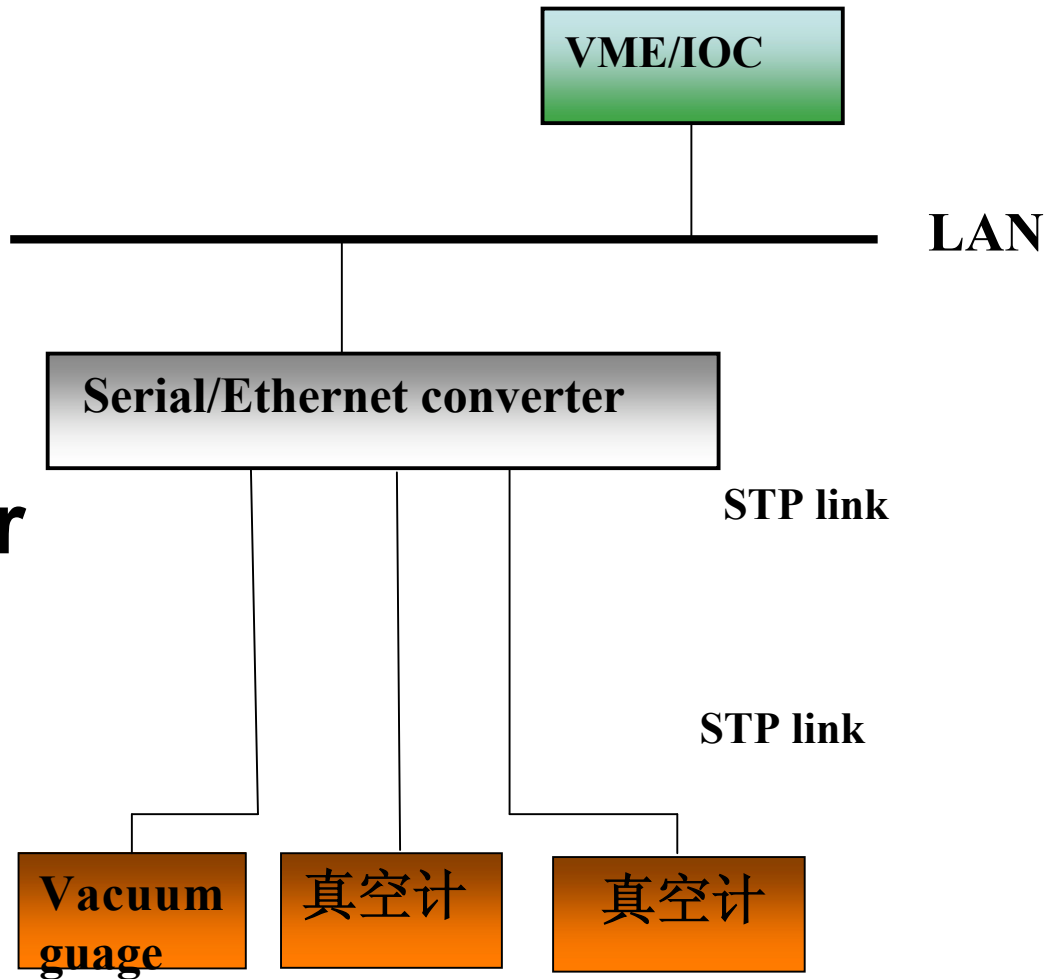
Device Control - Vacuum Monitor (Injector and Linac)



- **Epics: base-3.13.10**
- **O.S: vxWorks 5.3**
- **Device support/Driver:**
 - Support: devAscii
 - Carrier driver: drvIpac, drvVipc616
 - IP driver: drvOctal
 - Serial driver: drvSerial, drvAscii.

Device Control - Vacuum Monitor (Undulator)

- **Epics: base-3.14.8.2**
- **OS: vxWorks 5.5.1**
- **Device support/Driver**
 - asynDriver
 - streamDriver



Device control – Vacuum Pump

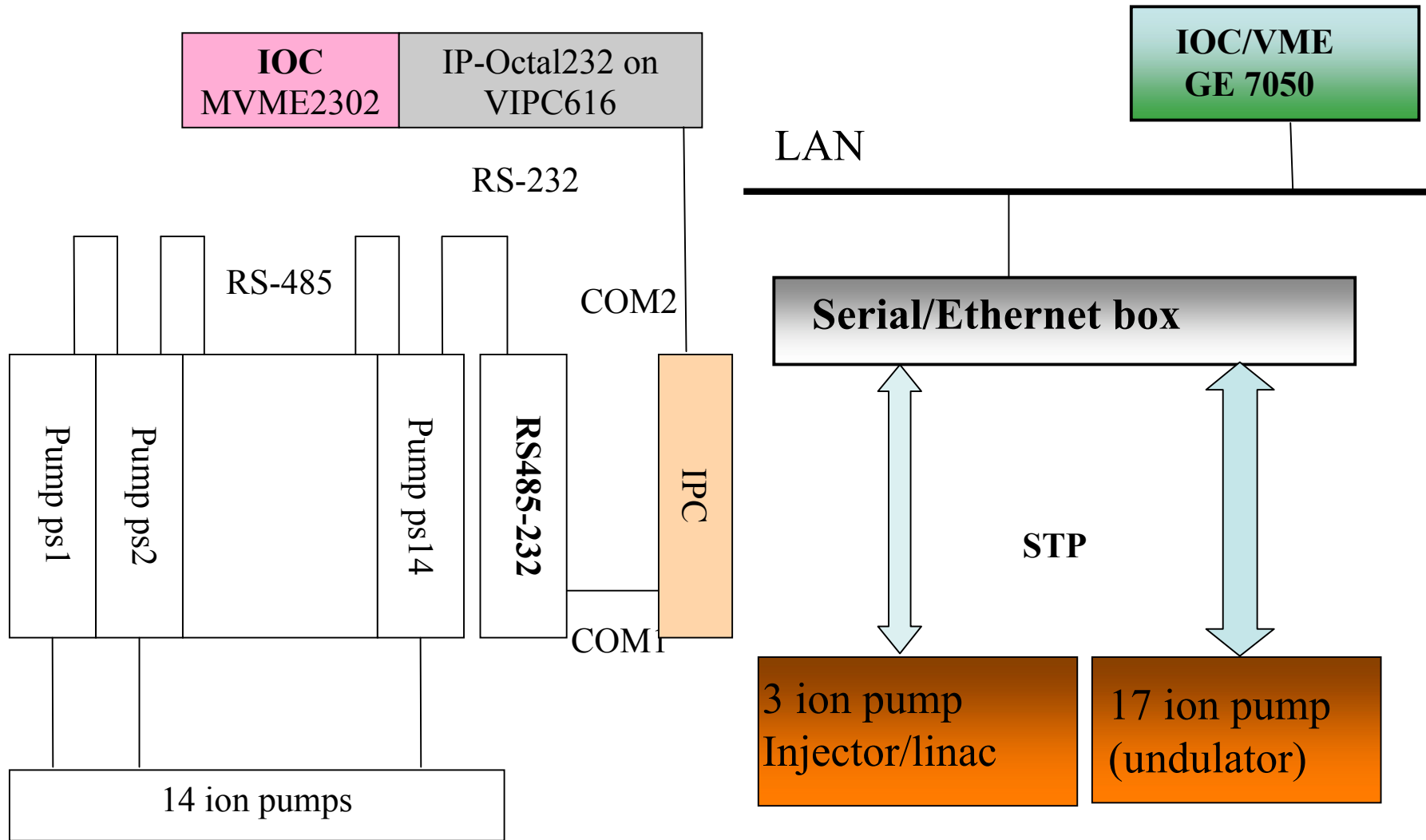
■ Injector and linac

- Keep old RS485 control method of 100Mev control in injector and linac
- 3 new pump supplies were added and controlled through Ethernet

■ Undulator

- 17 new pump power supplies
- Controlled through Ethernet

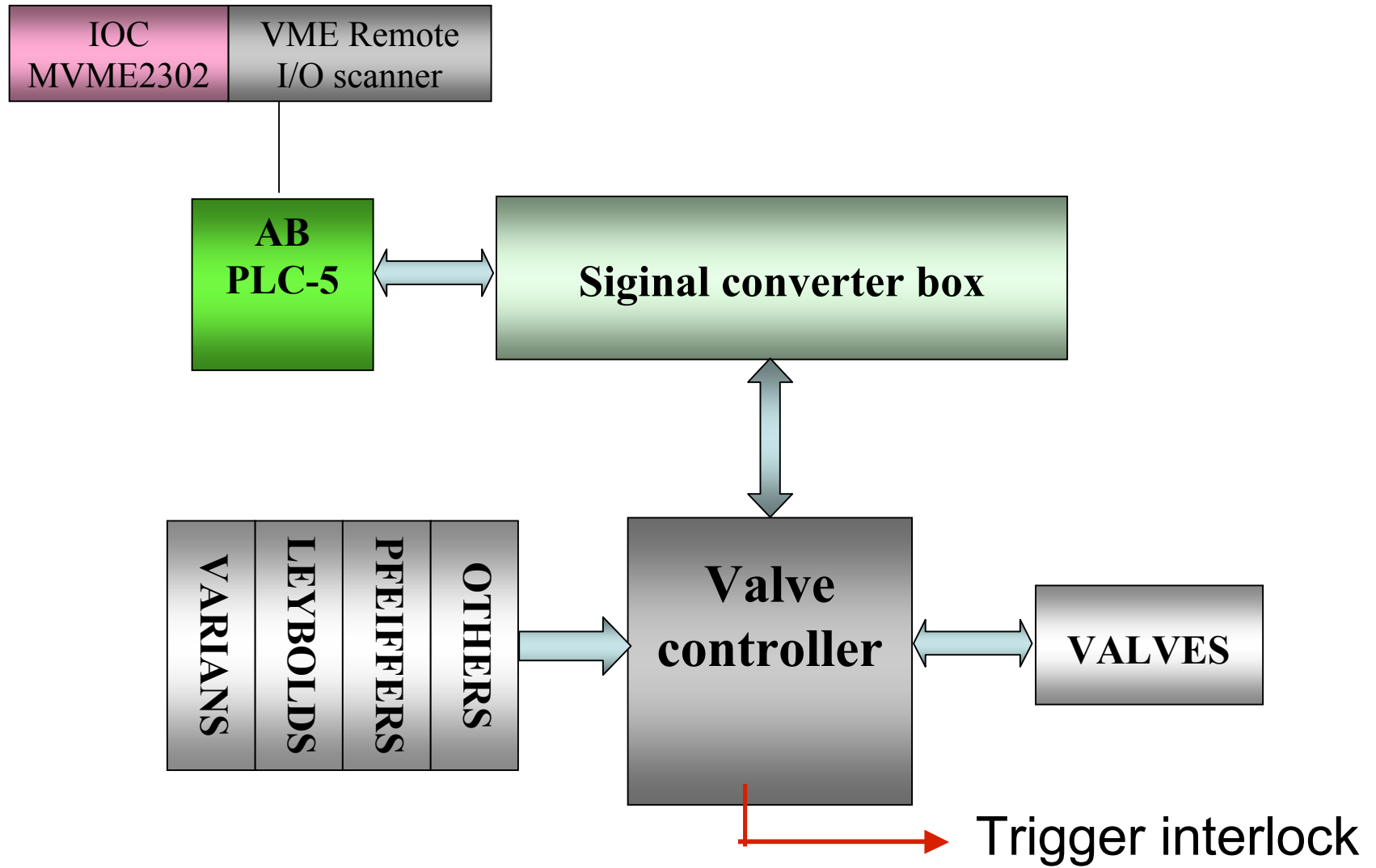
Device control – Vacuum Pump



Device Control - Valve Control

- Use AB PLC-5 to control valves and implement interlock
- There are 3 vacuum parts
 - Injector (valve V1,V2)
 - Linac (valve V2,V3)
 - Undulator (V4,V5)
- When the guage value reaches alarm, relay breaks, PLC output to close valves at both ends
- Comparing with old 100Mev control, 2 modules of 16 channels are added and new control logic was designed
- PLC communicate with VME/IOC based on AB's DCM protocol

Device Control - Valve Control



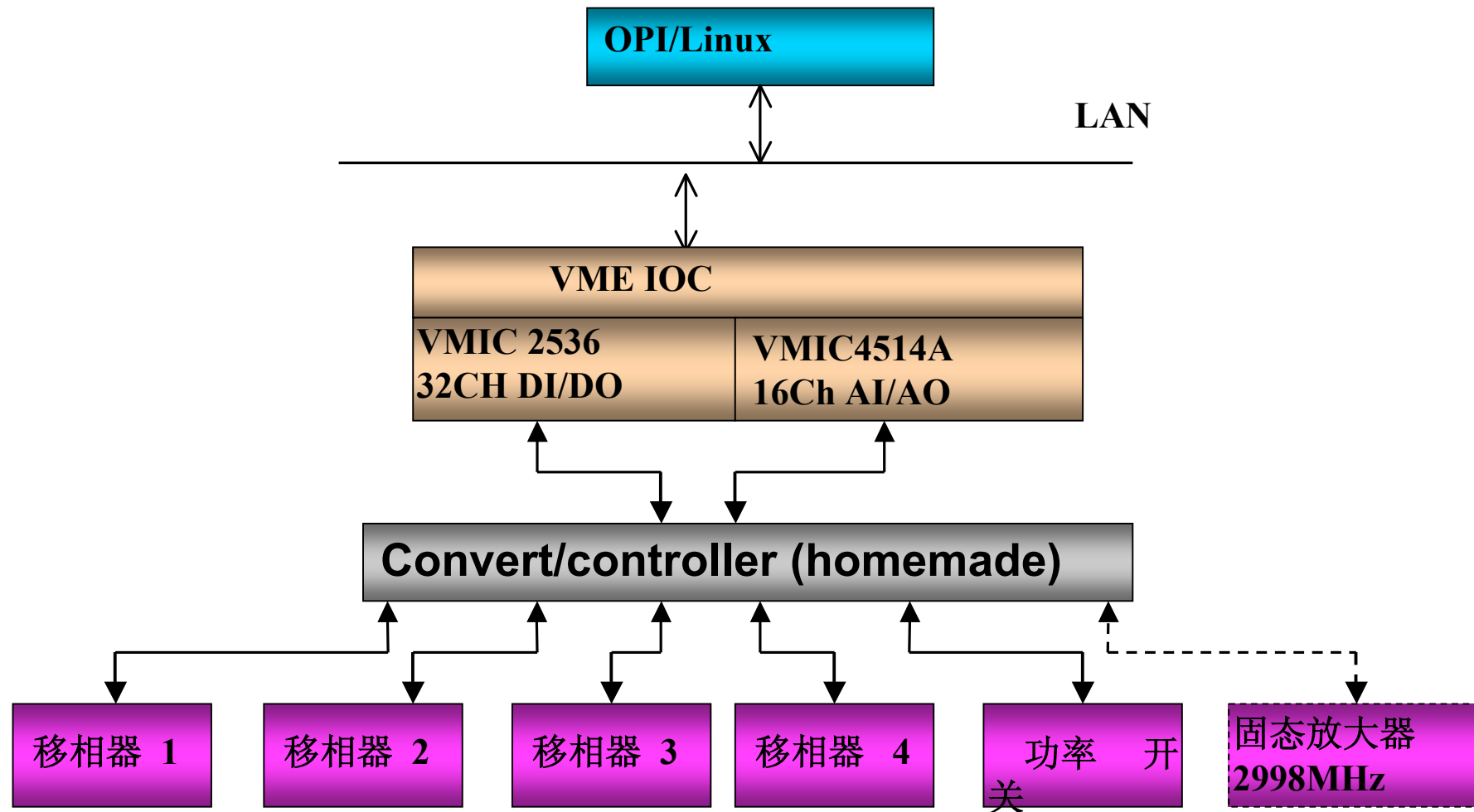
Device Control - Microwave

- One 2856MHz solid state amplifier's control
(Has been implemented in 100Mev)
- 4 high power phase shifter, 1 power switch
- 2 modulators (110MW/70MW)

Device Control – Phase Shifter

- Phase shifter (including power switch control) takes DC motors, each motor include
 - motor direction choice
 - Position control
 - Position current read back (0-10v)
- Use 100MeV Linac microwave control's free ports
 - IOC controls motors' digital/analog I/O
 - I/O modules' type is VMIC 2536(32 channel DI/DO)
 - Vmic4514A(16 channels AI/AO)

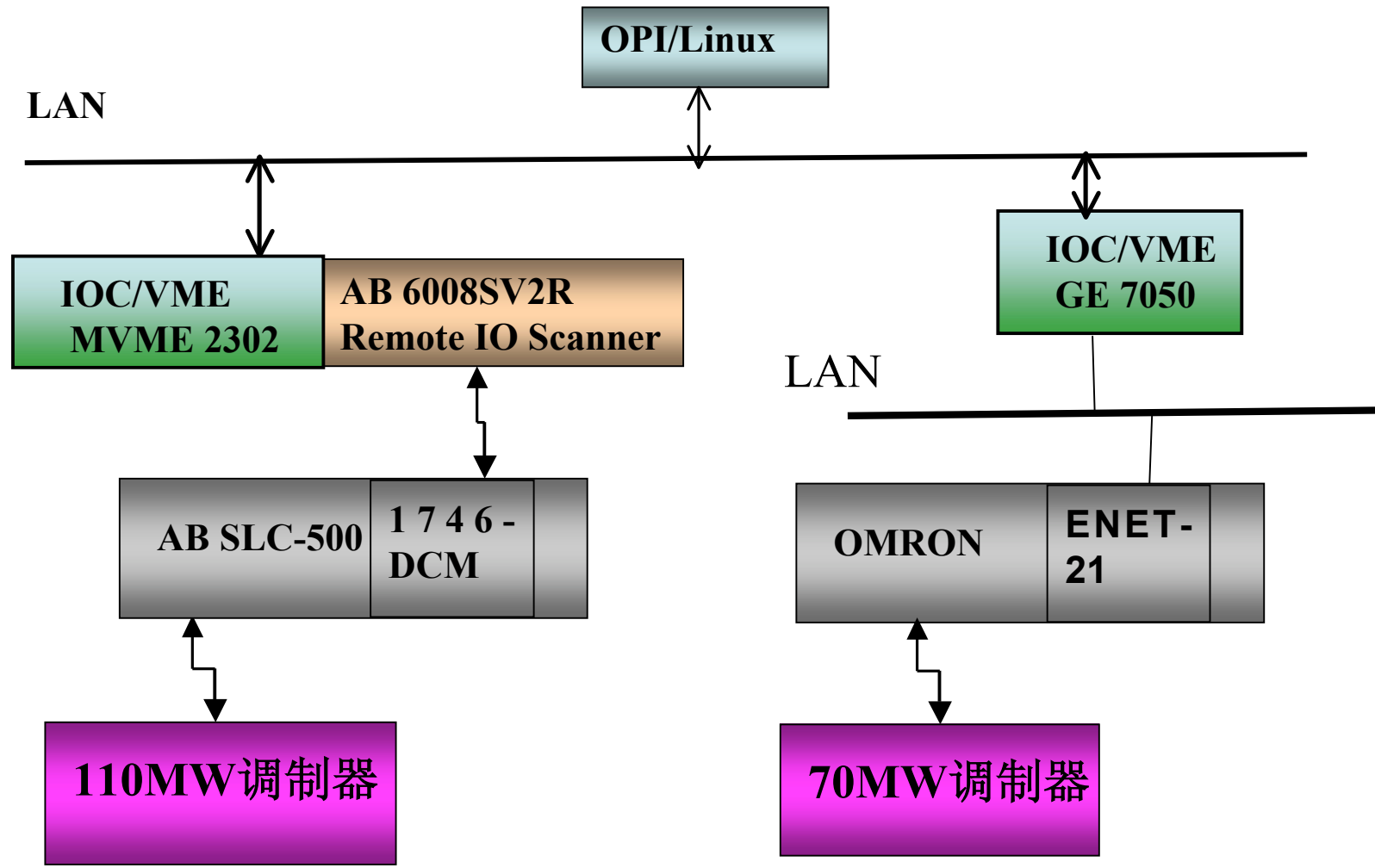
Device Control – Phase Shifter



Device Control – Modulator

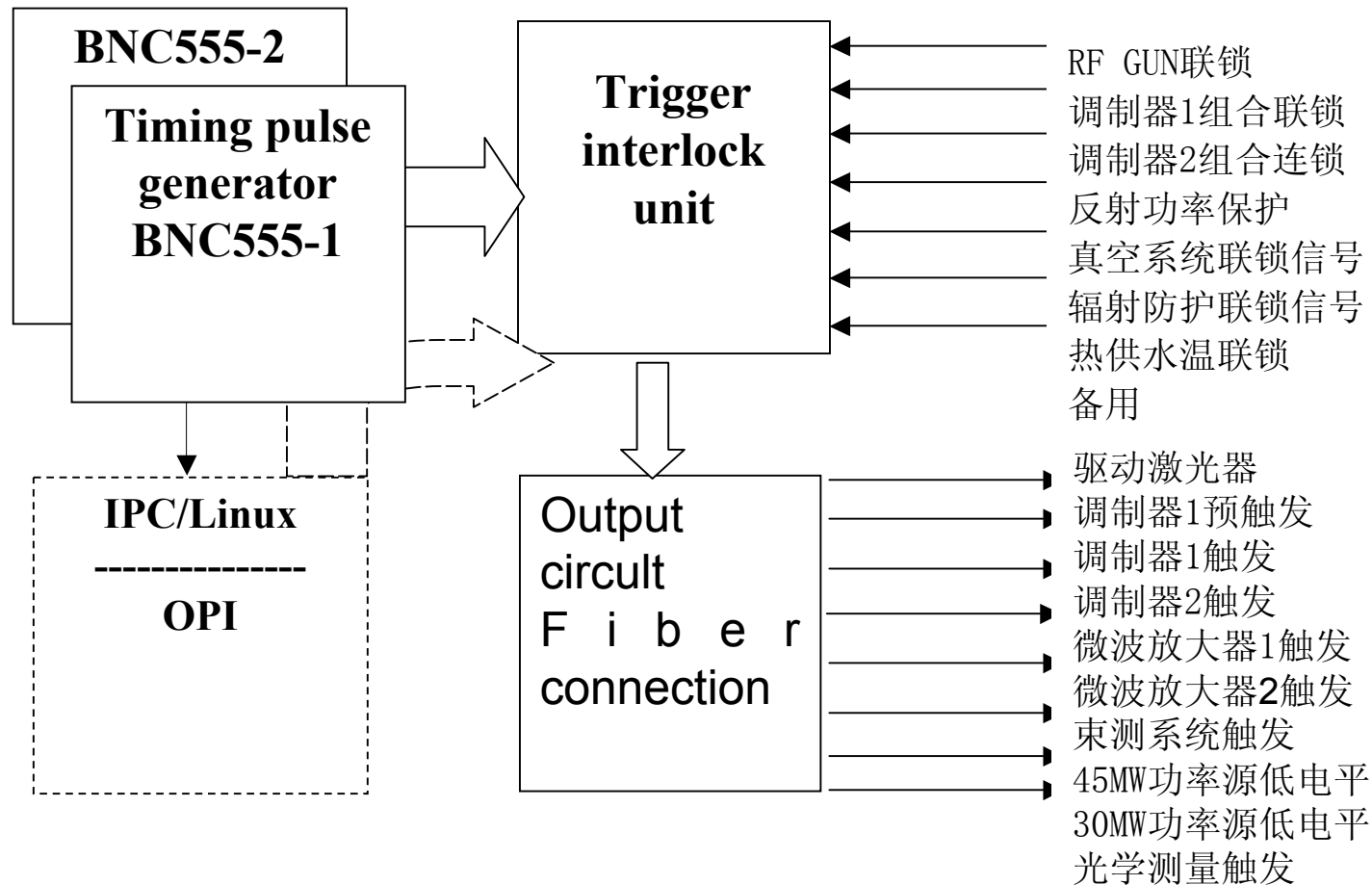
- 110MW modulator (old control system in 100Mev)
 - Local PLC (SLC-500) control with ladder
 - PLC communicates to IOC through Ethernet by 1746-DCM module
- 70MW modular (newly added device)
 - Local Omoron PLC control
 - Communicate to IOC through ethernet
- All control logic/interlock/execute/data acquisition are all finished by local PLC

Device Control – Modulator



Timing and Interlock

- Keep 100MeV design, use BNC company's MODEL 555-8 8 channels digital pulse delay generator



Timing and Interlock - Parameters

- Channels: 8
- Trigger types: Ext Trig, Ext Gate, Int, Single Shot, Burst, Duty Cycle
- Repeat freq: 0.01Hz-1.0 MHz
- Duty factor can be adjusted in each channel
- Output pulse range: CMOS/TTL
- Output pulse polarity can be choosed
- Output pulse width:10ns-100s, resolution1ns
- Output pulse delay:0-100s, resolution1ns
- Rising edge < 5ns

Others

■ Network

- 3 switch hubs locate on central control room, power supply room and device room, consist of local network

■ Video/broadcasting system

- keep old system

Thanks for your attention!

谢谢大家！